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**International Preliminary
Examination Report (IPER)
Amendments**

101593903

AMENDMENT

To : Examninaer of the Patent Office

5

1. Identification of the International Application

PCT/JP2004/003895

2. Applicant

10 Name : LUZCOM INC.

Address : 2-1, Sakado 3-chome, Takatsu-ku,
Kawasaki-shi, Kanagawa 213-0012 Japan

15 Country of nationality : Japan

Country of residence : Japan

3. Agent

20 Name : (9310) FUNATSU Nobuhiro

Address : Sakamoto & Funatsu, Takiyama Bldg. 5F, 7-12
Ginza 6-chome, Chuo-ku, Tokyo 104-0061 Japan

25 Name : (9277) SAKAMOTO Kiyotaka

Address : Sakamoto & Funatsu, Takiyama Bldg. 5F, 7-12
Ginza 6-chome, Chuo-ku, Tokyo 104-0061 Japan

4. Item to be Amended

Description and Claims

5 5. Contents of Amendment

(1) Delete Line 24 of Page 5 to Line 10 of Page
14 of the description.

Moreover, add the following to Line 24 of Page 5
to Page 13/2 of the description.

10 In a third aspect of the invention,

there is provided a tube by electroforming
producing method comprising the steps of: forming an
electrodeposit material or a surrounding material around a
thin wire material by electroforming ; and removing the
15 thin wire material from the electrodeposit material or the
surrounding material,

wherein the thin wire material is removed by
pulling the material from one end or both ends, deforming
the material so as to reduce a sectional area thereof, and
20 forming a clearance between the thin wire material and the
electrodeposit material or the surrounding material,
followed by gripping and pulling the thin wire material,
sucking the material, physically pushing away the material,
or blowing a gas or a liquid to push away the material.

25 In a fourth aspect of the invention,

there is provided the tube electroforming method
according to the third aspect of the invention,
wherein an amount of an end-portion-side

electrodeposit material or surrounding material to be formed on the thin wire material is increased.

In a fifth aspect of the invention,

there is provided the tube electroforming method

5 according to the third aspect of the invention,

wherein a deformation amount of a lateral distortion at a time when the thin wire material is pulled and extended outwards is 5% or more of the sectional area.

In a seventh aspect of the invention,

10 there is provided the tube electroforming method according to the third, fourth or fifth aspect of the invention,

wherein the thin wire material including a conductive layer disposed on an outer surface thereof is used, and the thin wire material is removed so that the conductive layer remains on an inner surface of a tube by 15 electroforming.

In an eighth aspect of the invention,

20 there is provided the tube electroforming method according to the third, fourth or fifth aspect of the invention,

wherein the thin wire material is used in which at least two conductive layers constituted of different materials are formed on an outer surface of the material, 25 the electrodeposit material or the surrounding material is brought into close contact with the outer conductive layer of the thin wire material, and the thin wire material is

removed so that the inner conductive layer remains on an inner surface of the tube by electroforming .

In a ninth aspect of the invention,

5 there is provided the tube electroforming method according to the third, fourth, fifth, seventh or eighth aspect of the invention,

wherein an inner shape of a hollow portion formed by removing the thin wire material from the electrodeposit material or the surrounding material has a circular 10 sectional shape or a polygonal sectional shape.

In a tenth aspect of the invention,

there is provided the tube electroforming method according to the third, fourth, fifth, seventh, eighth or ninth aspect of the invention,

15 wherein the tube by electroforming includes a plurality of hollow portions formed by removing the thin wire material.

In an eleventh aspect of the invention,

there is provided the tube electroforming method 20 according to the tenth aspect of the invention,

wherein a partition wall member formed by disposing a conductive layer on an outer surface of an insulator is disposed between the hollow portions, whereby each portion forming a periphery of each hollow portion 25 independently conducts electricity.

In a twelfth aspect of the invention,

there is provided a tube by electroforming

produced by forming an electrodeposit material or a surrounding material around a thin wire material by electroforming, and removing the thin wire material from the electrodeposit material or the surrounding material,

5 wherein a hollow portion is formed by removing the thin wire material from the electrodeposit material or the surrounding material, an inner diameter of the hollow portion is 10 μm or more and 85 μm or less, when an inner shape of the hollow portion has a circular sectional shape, 10 a diameter of an inscribed circle of the hollow portion is 10 μm or more and 85 μm or less, when the inner shape of the hollow portion has a polygonal sectional shape,

there are a plurality of hollow portions formed by removing the thin wire material, and

15 a partition wall member formed by disposing a conductive layer on an outer surface of an insulator is disposed between the hollow portions, whereby each portion forming a periphery of each hollow portion independently conducts electricity.

20 In a thirteenth aspect of the invention, there is provided the tube by electroforming according to the twelfth aspect of the invention, having a thickness of 5 μm or more and 50 μm or less.

25 In a fourteenth aspect of the invention, there is provided the tube by electroforming according to the twelfth or thirteenth aspect of the

invention,

having an inner surface provided with a conductive layer constituted of a material different from that of the electrodeposit material or the surrounding material.

5 In a fifteenth aspect of the invention,

there is provided the tube by electroforming according to the twelfth or thirteenth aspect of the invention,

10 having an inner surface of the tube is provided with a conductive layer constituted of a material different from that of the electrodeposit material or the surrounding material, a further conductive layer constituted of a material different from that of the conductive layer being disposed between the electrodeposit material or the 15 surrounding material and the conductive layer.

In an eighteenth aspect of the invention,

there is provided the tube by electroforming according to the twelfth, thirteenth, fourteenth or fifteenth aspect of the invention,

20 wherein the conductive layer disposed on the outer surface of the partition wall member is constituted to form a part of the hollow portion.

In a nineteenth aspect of the invention,

25 there is provided the tube by electroforming according to the twelfth, thirteenth, fourteenth, fifteenth or eighteenth aspect of the invention,

wherein a portion of the partition wall member

disposed between the hollow portions disposed adjacent to each other has a thickness of 5 μm or more and 50 μm or less.

In a twentieth aspect of the invention,

5 there is provided a thin wire material for production of a tube by electroforming produced by forming an electrodeposit material or a surrounding material around the thin wire material by electroforming , and removing the thin wire material from the electrodeposit material or the 10 surrounding material,

wherein an outer diameter of the thin wire material is 10 μm or more and 85 μm or less, when an outer shape of the thin wire material has a circular sectional shape, a diameter of an inscribed circle is 10 μm or more 15 and 85 μm or less, when the outer shape of the thin wire material has a polygonal sectional shape, and a deformation amount of a lateral distortion at a time when the thin wire material is pulled and extended outwards is 5% or more of a sectional area.

20 In a twenty-fifth aspect of the invention,

there is provided a thin wire material for production of a tube by electroforming produced by forming an electrodeposit material or a surrounding material around the thin wire material by electroforming , pulling the thin 25 wire material from one end or both ends to deform the material so that a sectional area thereof is reduced, forming a clearance between the thin wire material and the

electrodeposit material or the surrounding material to extract the thin wire material, and removing the thin wire material from the electrodeposit material or the surrounding material to produce a tube by electroforming,

5 wherein an outer diameter of the thin wire material is 10 μm or more and 85 μm or less, when an outer shape of the thin wire material has a circular sectional shape, a diameter of an inscribed circle is 10 μm or more and 85 μm or less, when the outer shape of the thin wire
10 material has a polygonal sectional shape, and a deformation amount of a lateral distortion at a time when the thin wire material is pulled and extended outwards is 5% or more of the sectional area.

15 In a twenty-sixth aspect of the invention, there is provided the thin wire material for the production of the tube by electroforming according to the twentieth or twenty-fifth aspect of the invention,

20 having an outer surface provided with a conductive layer constituted of a material different from that of the electrodeposit material or the surrounding material.

25 In a twenty-seventh aspect of the invention, there is provided the thin wire material for the production of the tube by electroforming according to the twentieth or twenty-fifth aspect of the invention,

 having an outer surface provided with a conductive layer constituted of a material different from that of the electrodeposit material or the surrounding material, and a

further conductive layer constituted of a material different from that of the conductive layer being disposed between a base member of the thin wire material and the conductive layer.

5 In a twenty-eighth aspect of the invention, there is provided the thin wire material for the production of the tube by electroforming according to the twentieth, twenty-fifth, twenty-sixth or twenty-seventh aspect of the invention,

10 wherein there are opposite end portions on which any conductive layer is not disposed.

In a twenty-ninth aspect of the invention, there is provided the thin wire material for the production of the tube by electroforming according to the twentieth, twenty-fifth, twenty-sixth, twenty-seventh or twenty-eighth aspect of the invention,

having an outer shape formed into a circular sectional shape or a polygonal sectional shape.

20 In a thirtieth aspect of the invention, there is provided a tube by electroforming produced by forming an electrodeposit material or a surrounding material around the thin wire material by electroforming, and removing the thin wire material from the electrodeposit material or the surrounding material,

25 wherein a hollow portion is formed by removing the thin wire material from the electrodeposit material or the surrounding material, an inner diameter of the hollow

portion is 10 μm or more and 85 μm or less, when an inner shape of the hollow portion has a circular sectional shape, and a diameter of an inscribed circle of the hollow portion is 10 μm or more and 85 μm or less, when the inner shape of 5 the hollow portion has a polygonal sectional shape.

In a thirty-first aspect of the invention, there is provided a tube by electroforming produced by forming an electrodeposit material or a surrounding material around the thin wire material by 10 electroforming, pulling the thin wire material from one end or both ends to deform the material so that a sectional area thereof is reduced, forming a clearance between the thin wire material and the electrodeposit material or the surrounding material to extract the thin wire material, and 15 removing the thin wire material from the electrodeposit material or the surrounding material,

wherein a hollow portion is formed by removing the thin wire material from the electrodeposit material or the surrounding material, an inner diameter of the hollow 20 portion is 10 μm or more and 85 μm or less, when an inner shape of the hollow portion has a circular sectional shape, and a diameter of an inscribed circle of the hollow portion is 10 μm or more and 85 μm or less, when the inner shape of 25 the hollow portion has a polygonal sectional shape.

In a thirty-second aspect of the invention, there is provided the tube by electroforming according to the thirtieth or thirty-first aspect of the

invention, having a thickness of 5 μm or more and 50 μm or less.

In a thirty-third aspect of the invention,
there is provided the tube by electroforming
according to the thirtieth, thirty-first or thirty-second
aspect of the invention,

having an inner surface provided with a conductive
layer constituted of a material different from that of the
electrodeposit material or the surrounding material.

In a thirty-fourth aspect of the invention,
there is provided the tube by electroforming
according to the thirtieth, thirty-first or thirty-second
aspect of the invention,

having an inner surface of the tube provided with
a conductive layer constituted of a material different from
that of the electrodeposit material or the surrounding
material, a further conductive layer constituted of a
material different from that of the conductive layer being
disposed between the electrodeposit material or the
surrounding material and the conductive layer.

In a thirty-fifth aspect of the invention,
there is provided the tube by electroforming
according to the thirty-first, thirty-second, thirty-third
or thirty-fourth aspect of the invention,

wherein there are a plurality of hollow portions
formed by removing the thin wire material.

(2) In Page 54 to 62 of the claims, delete Claims 1, 2, 6, 16, 17, 21, 22, 23 and 24, and add Claims 25 to 35.

Moreover, in Claim 3, amend "A tube by 5 electroforming producing method ..., characterized in that" to "A tube electroforming method ..., wherein".

In Claim 4, amend "according to claim 1, 2 or 3, characterized in that" to "according to claim 3, wherein".

10 In Claim 5, amend "according to claim 3, characterized in that" to "according to claim 3, wherein".

In Claim 7, amend "according to claim 1, 2, 3, 4, 5 or 6, characterized in that" to "according to claim 3, 4 or 5, wherein".

15 In Claim 8, amend "according to claim 1, 2, 3, 4, 5 or 6, characterized in that" to "according to claim 3, 4 or 5, wherein".

In Claim 9, amend "according to claim 1, 2, 3, 4, 5, 6, 7 or 8, characterized in that" to "according to claim 3, 4, 5, 7 or 8", wherein.

20 In Claim 10, amend "according to claim 1, 2, 3, 4, 5, 6, 7, 8 or 9, characterized in that" to "according to claim 3, 4, 5, 7, 8 or 9, wherein".

In Claim 11, amend "according to claim 10, characterized in that" to "according to claim 10, wherein".

25 Moreover, in Claim 12, amend "characterized in that a hollow portion is formed by removing the thin wire material from the electrodeposit material or the

surrounding material, an inner diameter of the hollow portion is 10 μm or more and 85 μm or less, when an inner shape of the hollow portion has a circular sectional shape, and a diameter of an inscribed circle of the hollow portion is 10 μm or more and 85 μm or less, when the inner shape of the hollow portion has a polygonal sectional shape." to

"wherein a hollow portion is formed by removing the thin wire material from the electrodeposit material or the surrounding material, an inner diameter of the hollow portion is 10 μm or more and 85 μm or less, when an inner shape of the hollow portion has a circular sectional shape, a diameter of an inscribed circle of the hollow portion is 10 μm or more and 85 μm or less, when the inner shape of the hollow portion has a polygonal sectional shape, there 15 are a plurality of hollow portions formed by removing the thin wire material, and a partition wall member formed by disposing a conductive layer on an outer surface of an insulating material is disposed between the hollow portions, whereby each portion forming a periphery of each 20 hollow portion independently conducts electricity."

In Claim 13, amend "according to claim 12, characterized in that" to "according to claim 12,".

In Claim 14, amend "according to claim 12 or 13, characterized in that" to "according to claim 12 or 13,".

25 In Claim 15, amend "according to claim 12 or 13, characterized in that" to "according to claim 12 or 13,".

In Claim 18, amend "according to claim 17,

characterized in that" to "according to claim 12, 13, 14 or 15, wherein".

In Claim 19, amend "according to claim 17 or 18, characterized in that" to "according to claim 12, 13, 14, 5 15 or 18, wherein".

In Claim 20, amend "A thin wire material for production of a tube by electroforming ..., characterized in" to "A thin wire material for production of a tube by electroforming ..., wherein".

10

6. List of Attached Documents

(1) Pages 5, 6, 7, 8, 9, 10, 11, 12, 13, 13/1, 13/2, and 14 of the specification

(2) Pages 54, 55, 56, 57, 58, 59, 60, 61, 62 and 15 62/1 of the claims

conductive layer and an electrodeposit material or a surrounding material, a tube by electroforming, and a thin wire material for production of the tube by electroforming;

5 (5) to provide a method of producing a tube by electroforming including a plurality of hollow portions, and a tube by electroforming;

10 (6) to provide a method of producing a tube by electroforming including a plurality of hollow portions so that each portion forming a periphery of each hollow portion can independently conduct electricity, and a tube by electroforming; and

15 (7) to provide a tube electroforming method in which a tensile force is not easily applied to a conductive layer disposed on an inner surface of a tube by electroforming in a case where a thin wire material is removed, whereby the conductive layer is easily separated from a base wire material, and a close contact property between the conductive layer and an electrodeposit material or a surrounding material is not easily impaired.

20

Disclosure of the Invention

Means of the present invention developed in order to achieve the above objects are as follows.

25 In a third aspect of the invention, there is provided a tube electroforming method comprising the steps of: forming an electrodeposit material or a surrounding material around a thin wire material by

electroforming; and removing the thin wire material from the electrodeposit material or the surrounding material,

wherein the thin wire material is removed by pulling the material from one end or both ends, deforming 5 the material so as to reduce a sectional area thereof, and forming a clearance between the thin wire material and the electrodeposit material or the surrounding material, followed by gripping and pulling the thin wire material, sucking the material, physically pushing away the material, 10 or blowing a gas or a liquid to push away the material.

In a fourth aspect of the invention,

there is provided the tube electroforming method according to the third aspect of the invention,

wherein an amount of an end-portion-side 15 electrodeposit or surrounding material to be formed on the thin wire material is increased.

In a fifth aspect of the invention,

there is provided the tube electroforming method according to the third aspect of the invention,

wherein a deformation amount of a lateral 20 distortion at a time when the thin wire material is pulled and extended outwards is 5% or more of the sectional area.

In a seventh aspect of the invention,

there is provided the tube electroforming method 25 according to the third, fourth or fifth aspect of the invention,

wherein the thin wire material including a

conductive layer disposed on an outer surface thereof is used, and the thin wire material is removed so that the conductive layer remains on an inner surface of a tube by electroforming.

5 In an eighth aspect of the invention, there is provided the tube electroforming method according to the third, fourth or fifth aspect of the invention,

10 wherein the thin wire material is used in which at least two conductive layers constituted of different materials are formed on an outer surface of the material, the electrodeposit material or the surrounding material is brought into close contact with the outer conductive layer of the thin wire material, and the thin wire material is 15 removed so that the inner conductive layer remains on an inner surface of the tube by electroforming.

15 In a ninth aspect of the invention, there is provided the tube electroforming method according to the third, fourth, fifth, seventh or eighth 20 aspect of the invention,

 wherein an inner shape of a hollow portion formed by removing the thin wire material from the electrodeposit material or the surrounding material has a circular sectional shape or a polygonal sectional shape.

25 In a tenth aspect of the invention, there is provided the tube electroforming method according to the third, fourth, fifth, seventh, eighth or

ninth aspect of the invention,

wherein the tube by electroforming includes a plurality of hollow portions formed by removing the thin wire material.

5 In an eleventh aspect of the invention,

there is provided the tube electroforming method according to the tenth aspect of the invention,

10 wherein a partition wall member formed by disposing a conductive layer on an outer surface of an insulating material is disposed between the hollow portions, whereby each portion forming a periphery of each hollow portion independently conducts electricity.

In a twelfth aspect of the invention,

15 there is provided a tube by electroforming produced by forming an electrodeposit material or a surrounding material around a thin wire material by electroforming, and removing the thin wire material from the electrodeposit material or the surrounding material,

20 wherein a hollow portion is formed by removing the thin wire material from the electrodeposit material or the surrounding material, an inner diameter of the hollow portion is 10 μm or more and 85 μm or less, when an inner shape of the hollow portion has a circular sectional shape, a diameter of an inscribed circle of the hollow portion is 25 10 μm or more and 85 μm or less, when the inner shape of the hollow portion has a polygonal sectional shape,

there are a plurality of hollow portions formed by

removing the thin wire material, and

a partition wall member formed by disposing a conductive layer on an outer surface of an insulating material is disposed between the hollow portions, whereby each portion forming a periphery of each hollow portion independently conducts electricity.

In a thirteenth aspect of the invention,

there is provided the tube by electroforming according to the twelfth aspect of the invention,

10 having a thickness of 5 μm or more and 50 μm or less.

In a fourteenth aspect of the invention,

there is provided the tube by electroforming according to the twelfth or thirteenth aspect of the 15 invention,

having an inner surface provided with a conductive layer constituted of a material different from that of the electrodeposit material or the surrounding material.

In a fifteenth aspect of the invention,

20 there is provided the tube by electroforming according to the twelfth or thirteenth aspect of the invention,

having an inner surface of the tube is provided with a conductive layer constituted of a material different 25 from that of the electrodeposit material or the surrounding material, a further conductive layer constituted of a material different from that of the conductive layer being

disposed between the electrodeposit material or the surrounding material and the conductive layer.

In an eighteenth aspect of the invention,
there is provided the tube by electroforming
5 according to the twelfth, thirteenth, fourteenth or
fifteenth aspect of the invention,

wherein the conductive layer disposed on the outer surface of the partition wall member is constituted to form a part of the hollow portion.

10 In a nineteenth aspect of the invention,
there is provided the tube by electroforming
according to the twelfth, thirteenth, fourteenth, fifteenth or eighteenth aspect of the invention,

15 wherein a portion of the partition wall member disposed between the hollow portions disposed adjacent to each other has a thickness of 5 μm or more and 50 μm or less.

20 In a twentieth aspect of the invention,
there is provided a thin wire material for production of a tube by electroforming produced by forming an electrodeposit material or a surrounding material around the thin wire material by electroforming, and removing the thin wire material from the electrodeposit material or the surrounding material,

25 wherein an outer diameter of the thin wire material is 10 μm or more and 85 μm or less, when an outer shape of the thin wire material has a circular sectional

shape, a diameter of an inscribed circle is 10 μm or more and 85 μm or less, when the outer shape of the thin wire material has a polygonal sectional shape, and a deformation amount of a lateral distortion at a time when the thin wire 5 material is pulled and extended outwards is 5% or more of a sectional area.

In a twenty-fifth aspect of the invention,
there is provided a thin wire material for
production of a tube by electroforming produced by forming
10 an electrodeposit material or a surrounding material around
the thin wire material by electroforming, pulling the thin
wire material from one end or both ends to deform the
material so that a sectional area thereof is reduced,
forming a clearance between the thin wire material and the
15 electrodeposit material or the surrounding material to
extract the thin wire material, and removing the thin wire
material from the electrodeposit material or the
surrounding material to produce a tube by electroforming,
wherein an outer diameter of the thin wire
20 material is 10 μm or more and 85 μm or less, when an outer
shape of the thin wire material has a circular sectional
shape, a diameter of an inscribed circle is 10 μm or more
and 85 μm or less, when the outer shape of the thin wire
material has a polygonal sectional shape, and a deformation
25 amount of a lateral distortion at a time when the thin wire
material is pulled and extended outwards is 5% or more of
the sectional area.

In a twenty-sixth aspect of the invention,
there is provided the thin wire material for the
production of the tube by electroforming according to the
twentieth or twenty-fifth aspect of the invention,

5 having an outer surface provided with a conductive
layer constituted of a material different from that of the
electrodeposit material or the surrounding material.

In a twenty-seventh aspect of the invention,
there is provided the thin wire material for the
10 production of the tube by electroforming according to the
twentieth or twenty-fifth aspect of the invention,

15 having an outer surface provided with a conductive
layer constituted of a material different from that of the
electrodeposit material or the surrounding material, and a
further conductive layer constituted of a material
different from that of the conductive layer being disposed
between a base member of the thin wire material and the
conductive layer.

In a twenty-eighth aspect of the invention,
20 there is provided the thin wire material for the
production of the tube by electroforming according to the
twentieth, twenty-fifth, twenty-sixth, twenty-seventh or
twenty-eighth aspect of the invention,

25 wherein there are opposite end portions on which
any conductive layer is not disposed.

In a twenty-ninth aspect of the invention,
there is provided the thin wire material for the

production of the tube by electroforming according to the twentieth, twenty-fifth, twenty-sixth, twenty-seventh or twenty-eighth aspect of the invention,

5 having an outer shape formed into a circular sectional shape or a polygonal sectional shape.

In a thirtieth aspect of the invention,

10 there is provided a tube by electroforming produced by forming an electrodeposit material or a surrounding material around the thin wire material by electroforming, and removing the thin wire material from the electrodeposit material or the surrounding material,

15 wherein a hollow portion is formed by removing the thin wire material from the electrodeposit material or the surrounding material, an inner diameter of the hollow portion is 10 μm or more and 85 μm or less, when an inner shape of the hollow portion has a circular sectional shape, and a diameter of an inscribed circle of the hollow portion is 10 μm or more and 85 μm or less, when the inner shape of the hollow portion has a polygonal sectional shape.

20 In a thirty-first aspect of the invention,

25 there is provided a tube by electroforming produced by forming an electrodeposit material or a surrounding material around the thin wire material by electroforming, pulling the thin wire material from one end or both ends to deform the material so that a sectional area thereof is reduced, forming a clearance between the thin wire material and the electrodeposit material or the

surrounding material to extract the thin wire material, and removing the thin wire material from the electrodeposit material or the surrounding material,

wherein a hollow portion is formed by removing the
5 thin wire material from the electrodeposit material or the surrounding material, an inner diameter of the hollow portion is 10 μm or more and 85 μm or less, when an inner shape of the hollow portion has a circular sectional shape, and a diameter of an inscribed circle of the hollow portion
10 is 10 μm or more and 85 μm or less, when the inner shape of the hollow portion has a polygonal sectional shape.

In a thirty-second aspect of the invention,
there is provided the tube by electroforming
according to the thirtieth or thirty-first aspect of the
15 invention, having a thickness of 5 μm or more and 50 μm or less.

In a thirty-third aspect of the invention,
there is provided the tube by electroforming
according to the thirtieth, thirty-first or thirty-second
20 aspect of the invention,

having an inner surface provided with a conductive layer constituted of a material different from that of the electrodeposit material or the surrounding material.

In a thirty-fourth aspect of the invention,
25 there is provided the tube by electroforming
according to the thirtieth, thirty-first or thirty-second aspect of the invention,

having an inner surface of the tube provided with
a conductive layer constituted of a material different from
that of the electrodeposit material or the surrounding
material, a further conductive layer constituted of a
5 material different from that of the conductive layer being
disposed between the electrodeposit material or the
surrounding material and the conductive layer.

In a thirty-fifth aspect of the invention,
there is provided the tube by electroforming
10 according to the thirtieth, thirty-second, thirty-third or
thirty-fourth aspect of the invention,
wherein there are a plurality of hollow portions
formed by removing the thin wire material.

5

10

As to the thin wire material, there can be used a material such as a metal wire material entirely formed of a conductive material, or a material formed by disposing the conductive layer (e.g., a metal such as plating, carbon or the like) around the conductive material. Alternatively, there can be used a material formed by using a thin wire material formed of an insulating material, such as a synthetic resin wire material, and disposing a conductive layer (e.g., a metal such as electroless plating, carbon or the like) around this material.

Furthermore, in a case where a separate conductor is disposed in the vicinity of the thin wire material, and a metal is electrodeposited (deposited) on the conductor, in addition to the above thin wire material, there can further be used a material entirely formed of an insulating material (any conductive material is not disposed), such as the synthetic resin wire material.

CLAIMS

1. (deleted)

5 2. (deleted)

3. (corrected) A tube electroforming method comprising the steps of: forming an electrodeposit material or a surrounding material around a thin wire material by 10 electroforming; and removing the thin wire material from the electrodeposit material or the surrounding material, wherein the thin wire material is removed by pulling the material from one end or both ends, deforming the material so as to reduce a sectional area thereof, and 15 forming a clearance between the thin wire material and the electrodeposit material or the surrounding material, followed by gripping and pulling the thin wire material, sucking the material, physically pushing away the material, or blowing a gas or a liquid to push away the material.

20

4. (corrected) The tube electroforming method according to claim 3,

25 wherein an amount of an end-portion-side electrodeposit or surrounding material to be formed on the thin wire material is increased.

5. (corrected) The tube electroforming method

according to claim 3,

wherein a deformation amount of a lateral distortion at a time when the thin wire material is pulled and extended outwards is 5% or more of the sectional area.

5

6. (deleted)

7. (corrected) The tube electroforming method according to claim 3, 4 or 5,

10 wherein the thin wire material including a conductive layer disposed on an outer surface thereof is used, and the thin wire material is removed so that the conductive layer remains on an inner surface of a tube by electroforming.

15

8. (corrected) The tube electroforming method according to claim 3, 4 or 5,

20 wherein the thin wire material is used in which at least two conductive layers constituted of different materials are formed on an outer surface of the material, the electrodeposit material or the surrounding material is brought into close contact with the outer conductive layer of the thin wire material, and the thin wire material is removed so that the inner conductive layer remains on an 25 inner surface of the tube by electroforming.

9. (corrected) The tube electroforming method

according to claim 3, 4, 5, 7 or 8,

wherein an inner shape of a hollow portion formed by removing the thin wire material from the electrodeposit material or the surrounding material has a circular
5 sectional shape or a polygonal sectional shape.

10. (corrected) The tube electroforming method according to claim 3, 4, 5, 7, 8 or 9,

wherein the tube by electroforming includes a
10 plurality of hollow portions formed by removing the thin wire material.

11. (corrected) The tube electroforming method according to claim 10,

15 wherein a partition wall member formed by disposing a conductive layer on an outer surface of an insulating material is disposed between the hollow portions, whereby each portion forming a periphery of each hollow portion independently conducts electricity.

20
12. (corrected) A tube by electroforming produced by forming an electrodeposit material or a surrounding material around a thin wire material by electroforming, and removing the thin wire material from the electrodeposit
25 material or the surrounding material,

wherein a hollow portion is formed by removing the thin wire material from the electrodeposit material or the

surrounding material, an inner diameter of the hollow portion is 10 μm or more and 85 μm or less, when an inner shape of the hollow portion has a circular sectional shape, a diameter of an inscribed circle of the hollow portion is
5 10 μm or more and 85 μm or less, when the inner shape of the hollow portion has a polygonal sectional shape,

there are a plurality of hollow portions formed by removing the thin wire material, and

10 a partition wall member formed by disposing a conductive layer on an outer surface of an insulating material is disposed between the hollow portions, whereby each portion forming a periphery of each hollow portion independently conducts electricity.

15 13. (corrected) The tube by electroforming according to claim 12, having a thickness of 5 μm or more and 50 μm or less.

20 14. (corrected) The tube by electroforming according to claim 12 or 13, having an inner surface provided with a conductive layer constituted of a material different from that of the electrodeposit material or the surrounding material.

25 15. (corrected) The tube by electroforming according to claim 12 or 13, having an inner surface of the tube provided with a conductive layer constituted of a

material different from that of the electrodeposit material or the surrounding material, a further conductive layer constituted of a material different from that of the conductive layer being disposed between the electrodeposit 5 material or the surrounding material and the conductive layer.

16. (deleted)

10 17. (deleted)

18. (corrected) The tube by electroforming according to claim 12, 13, 14 or 15, wherein the conductive layer disposed on the outer surface of the partition wall 15 member is constituted to form a part of the hollow portion.

19. (corrected) The tube by electroforming according to claim 12, 13, 14, 15 or 18, wherein a portion of the partition wall member disposed between the hollow 20 portions disposed adjacent to each other has a thickness of 5 μm or more and 50 μm or less.

20. (corrected) A thin wire material for production of a tube by electroforming produced by forming 25 an electrodeposit material or a surrounding material around the thin wire material by electroforming, and removing the thin wire material from the electrodeposit material or the

surrounding material,

wherein an outer diameter of the thin wire material is 10 μm or more and 85 μm or less, when an outer shape of the thin wire material has a circular sectional shape, a diameter of an inscribed circle is 10 μm or more and 85 μm or less, when the outer shape of the thin wire material has a polygonal sectional shape, and a deformation amount of a lateral distortion at a time when the thin wire material is pulled and extended outwards is 5% or more of a sectional area.

21. (deleted)

22. (deleted)

15

23. (deleted)

24. (deleted)

20 25. (added) A thin wire material for production of a tube by electroforming produced by forming an electrodeposit material or a surrounding material around the thin wire material by electroforming, pulling the thin wire material from one end or both ends to deform the material so that a sectional area thereof is reduced, forming a clearance between the thin wire material and the electrodeposit material or the surrounding material to

extract the thin wire material, and removing the thin wire material from the electrodeposit material or the surrounding material to produce a tube by electroforming,

wherein an outer diameter of the thin wire

5 material is 10 μm or more and 85 μm or less, when an outer shape of the thin wire material has a circular sectional shape, a diameter of an inscribed circle is 10 μm or more and 85 μm or less, when the outer shape of the thin wire material has a polygonal sectional shape, and a deformation 10 amount of a lateral distortion at a time when the thin wire material is pulled and extended outwards is 5% or more of the sectional area.

26. (added) The thin wire material for the

15 production of the tube by electroforming according to claim 20 or 25, having an outer surface provided with a conductive layer constituted of a material different from that of the electrodeposit material or the surrounding material.

20

27. (added) The thin wire material for the

25 production of the tube by electroforming according to claim 20 or 25, having an outer surface of the material provided with a conductive layer constituted of a material different from that of the electrodeposit material or the surrounding material, a further conductive layer constituted of a material different from that of the conductive layer being

disposed between a base member of the thin wire material and the conductive layer.

28. (added) The thin wire material for the
5 production of the tube by electroforming according to claim
20, 25, 26, 27 or 28, wherein there are opposite end
portions on which any conductive layer is not disposed.

29. (added) The thin wire material for the
10 production of the tube by electroforming according to claim
20, 25, 26, 27 or 28, having an outer shape formed into a
circular sectional shape or a polygonal sectional shape.

30. (added) A tube by electroforming produced by
15 forming an electrodeposit material or a surrounding
material around the thin wire material by electroforming,
and removing the thin wire material from the electrodeposit
material or the surrounding material,

wherein a hollow portion is formed by removing the
20 thin wire material from the electrodeposit material or the
surrounding material, an inner diameter of the hollow
portion is 10 μm or more and 85 μm or less, when an inner
shape of the hollow portion has a circular sectional shape,
and a diameter of an inscribed circle of the hollow portion
25 is 10 μm or more and 85 μm or less, when the inner shape of
the hollow portion has a polygonal sectional shape.

31. (added) A tube by electroforming produced by forming an electrodeposit material or a surrounding material around the thin wire material by electroforming, pulling the thin wire material from one end or both ends to 5 deform the material so that a sectional area thereof is reduced, forming a clearance between the thin wire material and the electrodeposit material or the surrounding material to extract the thin wire material, and removing the thin wire material from the electrodeposit material or the 10 surrounding material,

wherein a hollow portion is formed by removing the thin wire material from the electrodeposit material or the surrounding material, an inner diameter of the hollow portion is 10 μm or more and 85 μm or less, when an inner 15 shape of the hollow portion has a circular sectional shape, and a diameter of an inscribed circle of the hollow portion is 10 μm or more and 85 μm or less, when the inner shape of the hollow portion has a polygonal sectional shape.

20 32. (added) The tube by electroforming according to claim 30 or 31, having a thickness of 5 μm or more and 50 μm or less.

25 33. (added) The tube by electroforming according to claim 30, 31 or 32, having an inner surface provided with a conductive layer constituted of a material different from that of the electrodeposit material or the surrounding

material.

34. (added) The tube by electroforming according to claim 30, 31 or 32, having an inner surface provided
5 with a conductive layer constituted of a material different from that of the electrodeposit material or the surrounding material, a further conductive layer constituted of a material different from that of the conductive layer being disposed between the electrodeposit material or the
10 surrounding material and the conductive layer.

35. (added) The tube by electroforming according to claim 31, 32, 33 or 34, wherein there are a plurality of hollow portions formed by removing the thin wire material.